

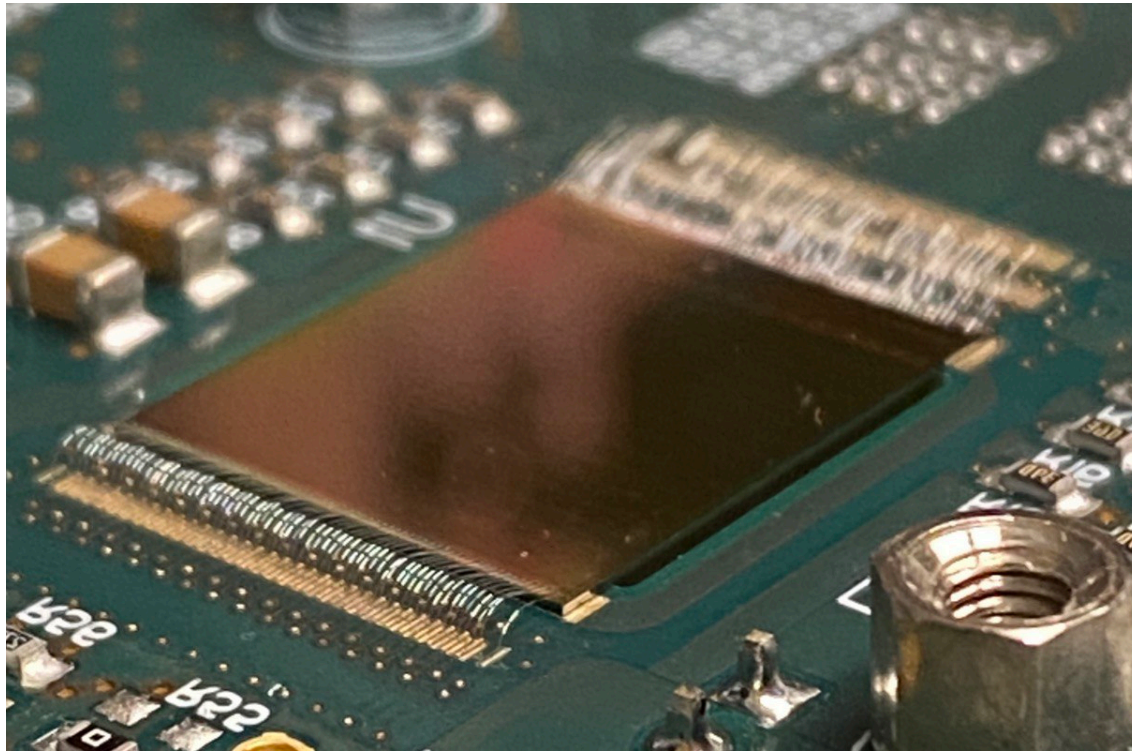


Istituto Nazionale di Fisica Nucleare

ARCADIA
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ARCADIA: technology platform and system-grade demonstrator architecture



Vertex 2021

Oxford, UK (Virtual)

September 29th, 2020

Andrea Paternò

on behalf of the ARCADIA Collaboration

ARCADIA (INFN CSNV Call Project)

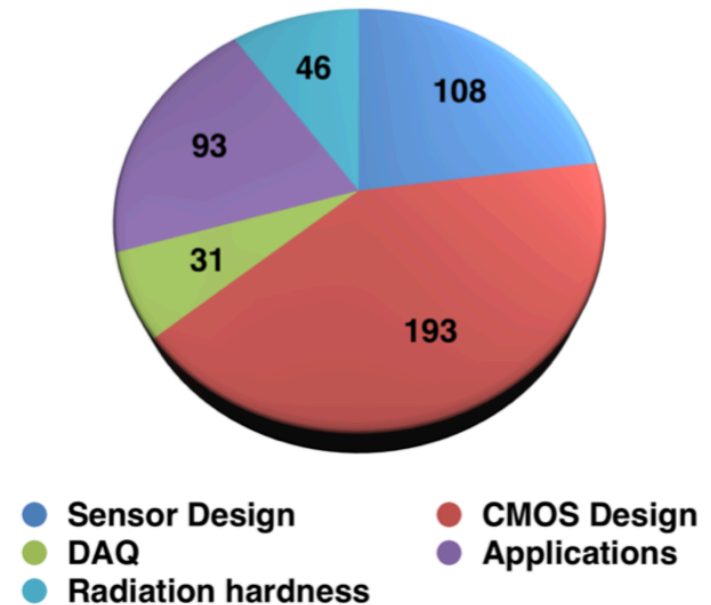


Advanced Readout CMOS Architectures with Depleted Integrated sensor Arrays

INFN - Bologna, Milano, Padova, Perugia, Pavia, TIFPA, Torino

F. Alfonsi, G. Ambrosi, A. Andreazza, E. Bianco, G. Balbi, S. Beolè, M. Caccia, A. Candelori, D. Chiappara, T. Corradino, T. Croci, M. Da Rocha Rolo, G. F. Dalla Betta, A. De Angelis, G. Dellacasa, N. Demaria, L. De Cilladi, B. Di Ruzza, A. Di Salvo, D. Falchieri, M. Favaro, A. Gabrielli, L. Gaioni, S. Garbolino, G. Gebbia, R. Giampaolo, N. Giangiacomi, P. Giubilato, R. Iuppa, M. Mandurrino, M. Manghisoni, S. Mattiazzo, M. Mignone, C. Neubüser, F. Nozzoli, J. Olave, L. Pancheri, D. Passeri, A. Paternò, M. Pezzoli, P. Placidi, L. Ratti, E. Ricci, S. B. Ricciarini, A. Rivetti, R. Santoro, A. Scorzoni, L. Servoli, F. Tosello, G. Traversi, C. Vacchi, R. Wheadon, J. Wyss, P. Zuccon

Person/month assignment per Work-Package



* 3-year >1M€ R&D project 2019-2021

* Sensor&CMOS design, DAQ, System characterisation (medical, future colliders, space)

ARCADIA (INFN CSNV Call Project)

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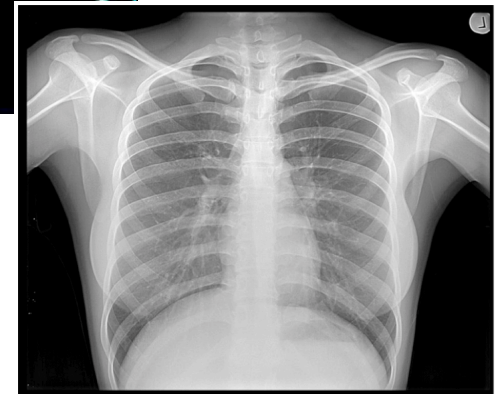
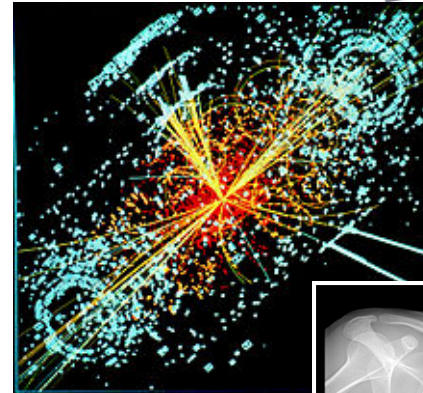
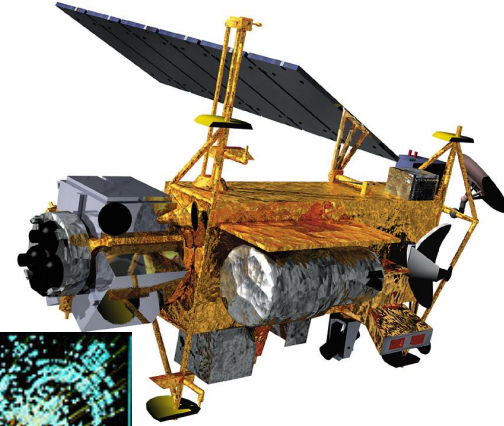
CMOS sensor design and fabrication platform allowing for:

- * Active sensor thickness in the range 50 μm to 500 μm
- * Operation in full depletion with fast charge collection only by drift
- * Small charge collecting electrode for optimal signal-to-noise ratio
- * Scalable readout architecture with ultra-low power capability (~ 20 mW/cm²)
- * Compatibility with standard CMOS fabrication processes: concept study with small-scale test structure (SEED), technology demonstration with large area sensors (ARCADIA)
- * Use of a deep sub-micron 110nm CMOS node for higher gate density

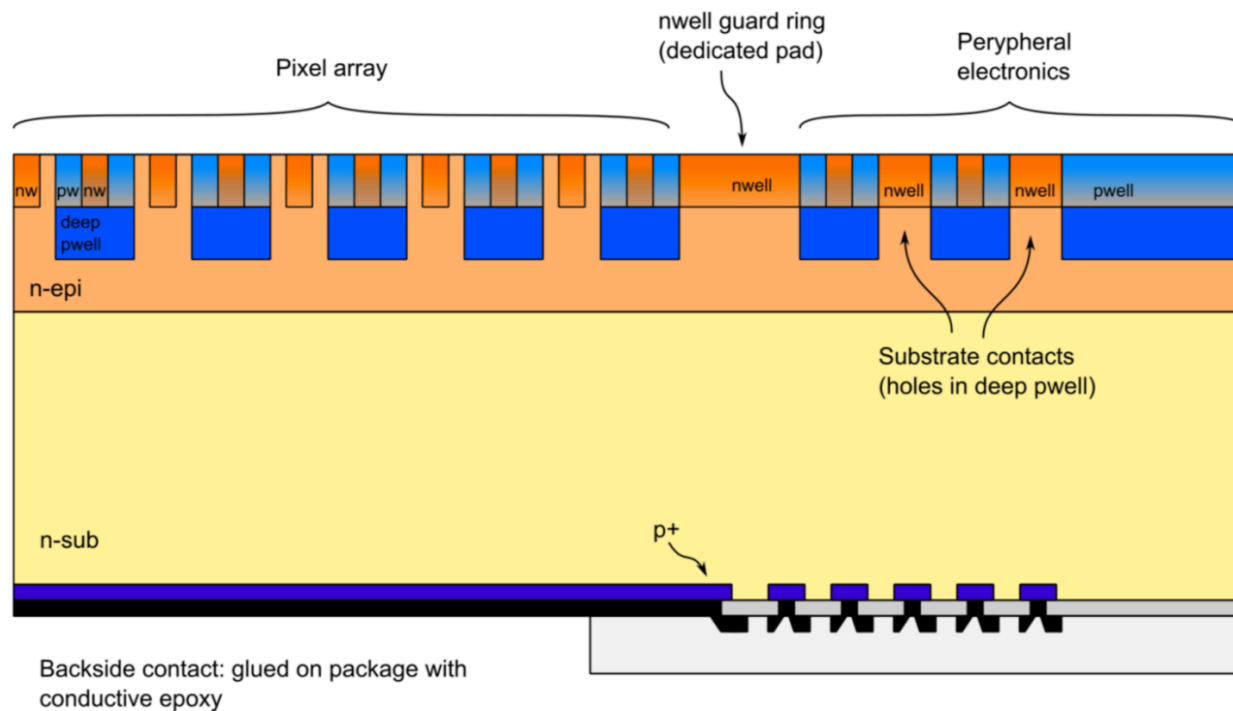
Specifications

Apply the experience developed with SEED to a versatile, full-chip prototype
Targeting most stringent requirements for a number of applications:

- * Low power $\rightarrow O(20 \text{ mW cm}^{-2})$
 - * Scale down to $O(10 \text{ mW cm}^{-2})$ in Low Rate mode
- * Small pixel pitch $\rightarrow 25 \times 25 \mu\text{m}^2$
- * Thin sensors $\rightarrow 100 \mu\text{m}$
- * Scalability to large area \rightarrow up to $4 \times 4 \text{ cm}^2$
- * High particle rate \rightarrow up to 100 MHz cm^{-2}
- * Timing resolution $\rightarrow O(1 \mu\text{s})$
 - * Investigating more advanced solutions for $O(10 \text{ ns})$ timing



The Sensor

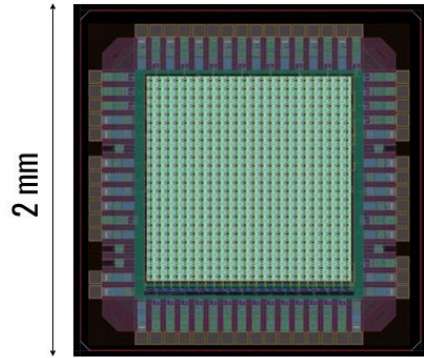


- * Prototypes: Pixel sensor w/ electronics (MATISSE) and passive test structures (Pseudo-Matrix)
- * Technology: 110 nm CMOS CIS technology (quad-well, both PMOS and NMOS), high-resistivity bulk
- * Backside: diode surrounded by a guard-ring, custom patterning, process developed with LFoundry
- * Process, back-side pattern and geometry validated in silicon

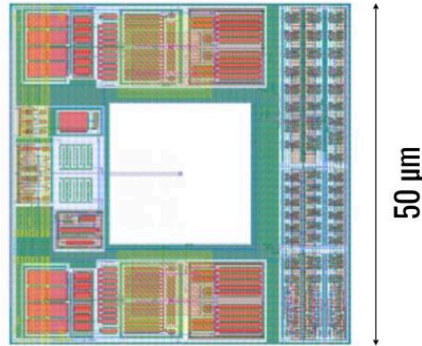
Prototypes



Small-scale demo: MATISSE



MATISSE



Pixel CAD Layout

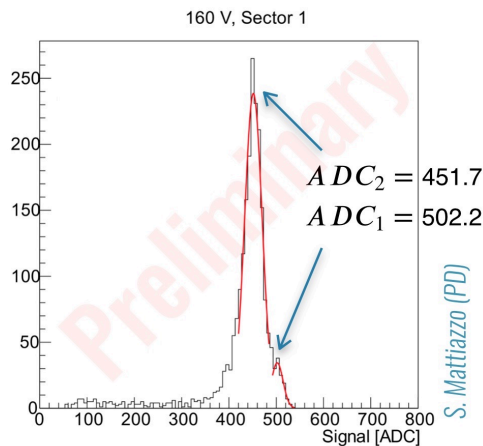
Pixels: Analog-only

Matrix: 24x24 pixels

Dynamic range: up to 40ke-

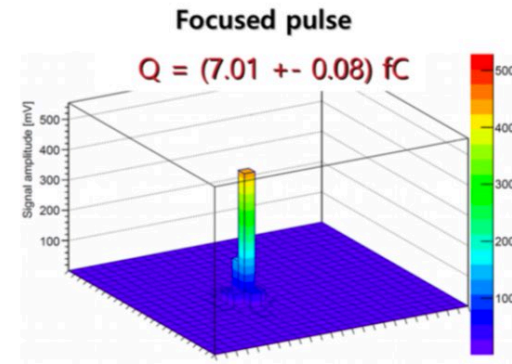
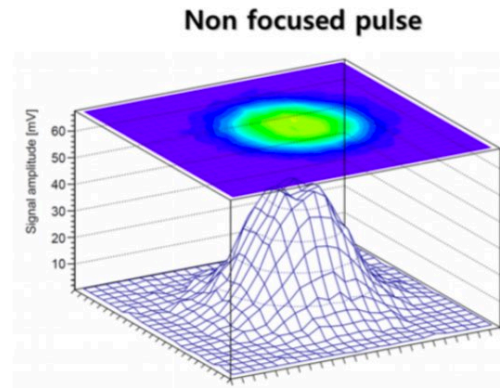
Noise: ~40e- (measured)

Preliminary results with ^{55}Fe



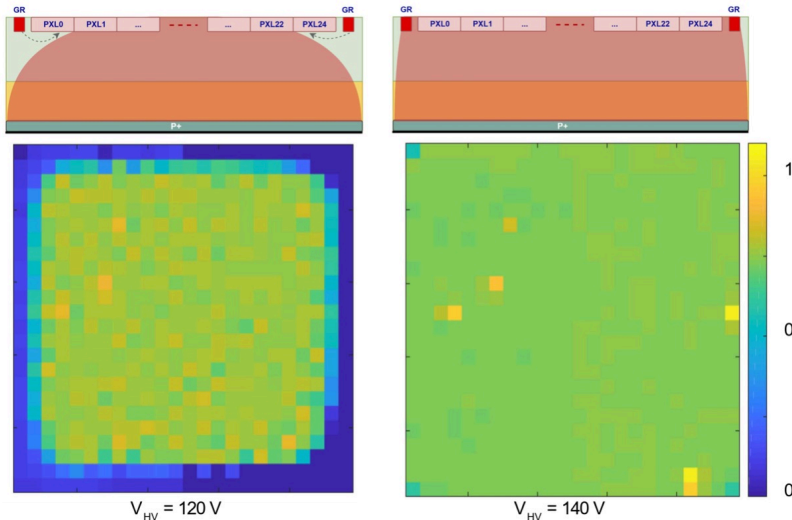
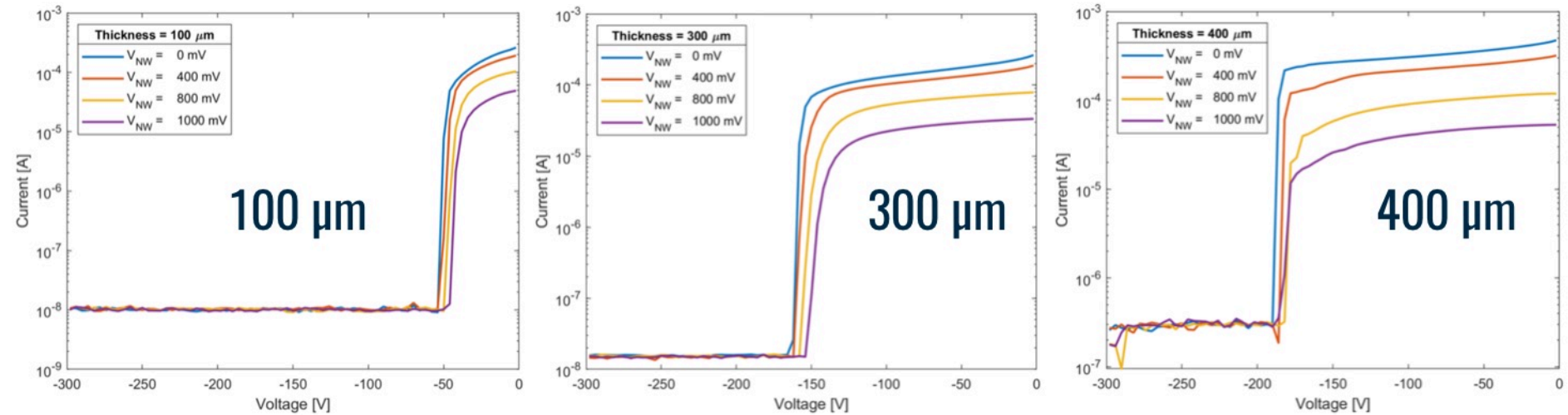
$$\frac{ADC_1}{ADC_2} \approx \frac{6.5 \text{ keV}}{5.9 \text{ keV}}$$

Preliminary results with Lasers



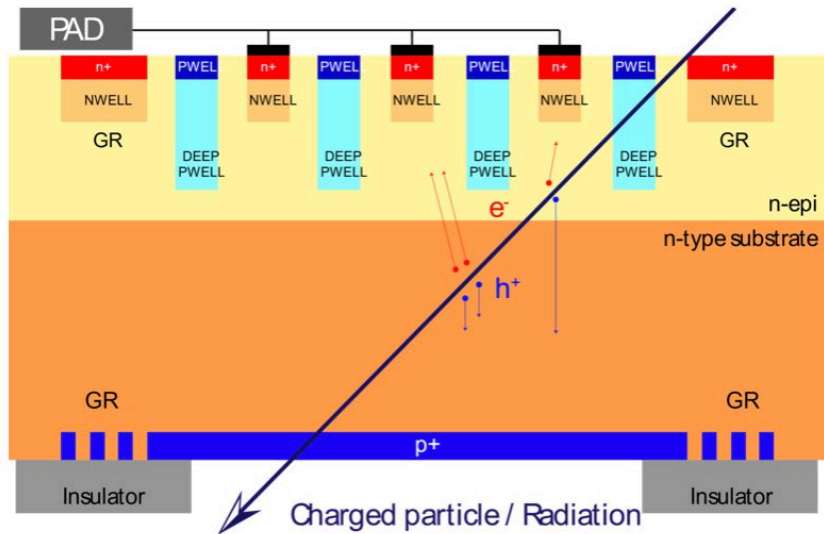
Results in a nutshell: MATISSE

Full depletion studies in 100-300-400 μm prototypes



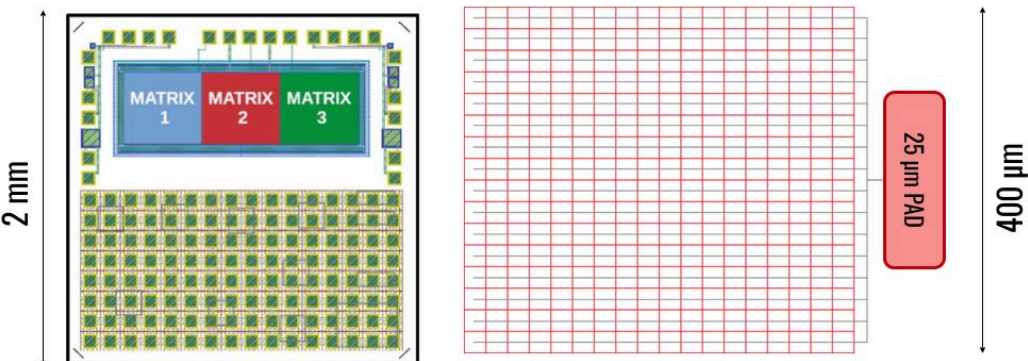
Map of pixel reset voltage (MATISSE 24x24 pixel matrix, 300 μm thickness) as a function of the back-side voltage applied to the sensor. Depletion starts from the back-side.

Small-scale demo: Pseudo-Matrices



- * Sensor **thicknesses**: 100 μm , 300 μm , 400 μm
- * Three matrices with different **pixel sizes**: 10 μm (40 x 45), 25 μm (16 x 18) and 50 μm (8 x 9)
- * Front-side **deep-pwell**, would host the CMOS electronics (no electronics on PMs)

- * All the collector nodes of a matrix are **shorted** and connected to a PAD
- * Each pixel is shorted using **Al metal lines** of increasing width per PM: 6, 8 and 15 μm



Pseudo-matrix Layout

Pixel Scheme

Results in a nutshell: Pseudo-Matrices

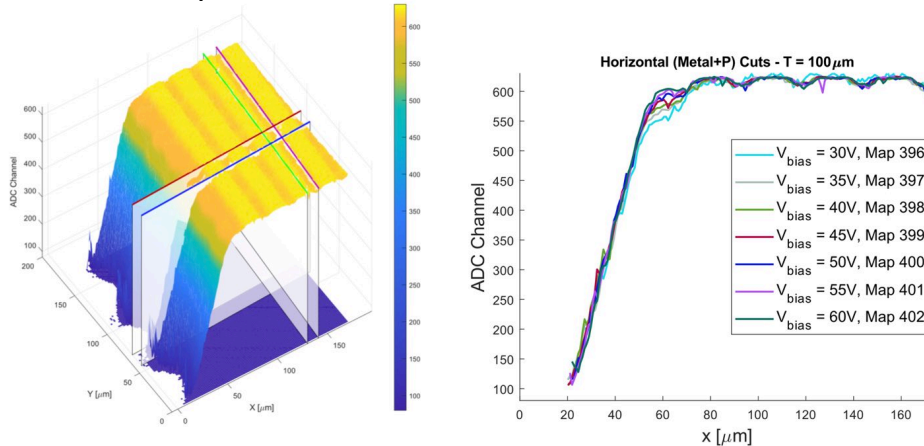
Cuts along the **Metal + P** and **Metal + N** lines on the energy map with varying bias voltages show **uniform Charge Collection Efficiency** above Full Depletion with $\sim 1.7\%$ loss over metals (100 μm thick)

(**RUĐER BOŠKOVIĆ INSTITUTE**)* Zagreb, Croatia

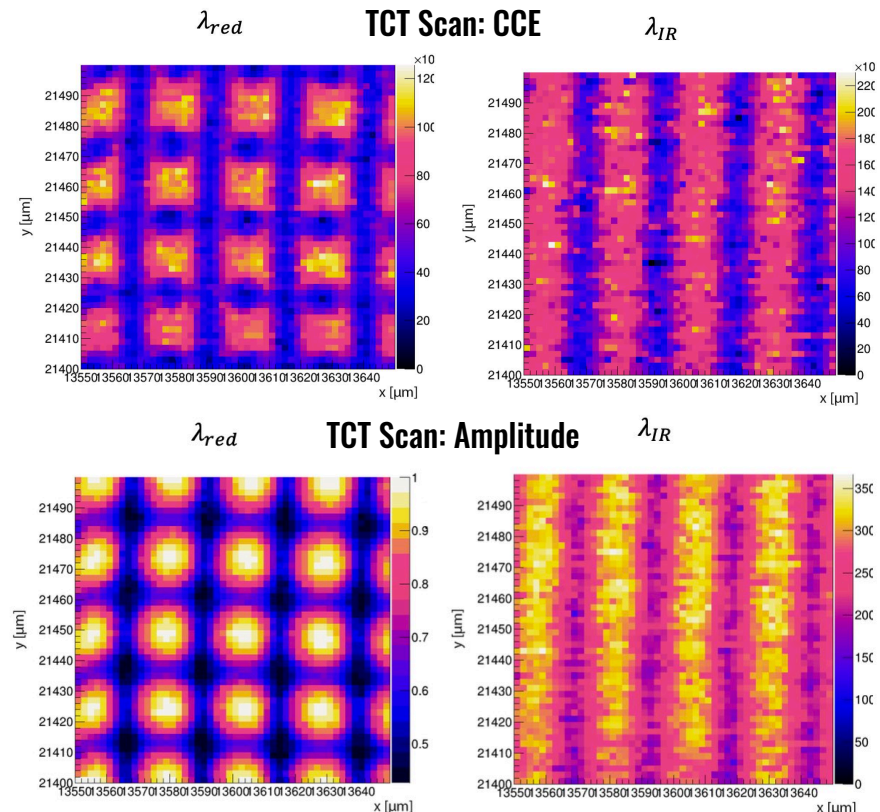
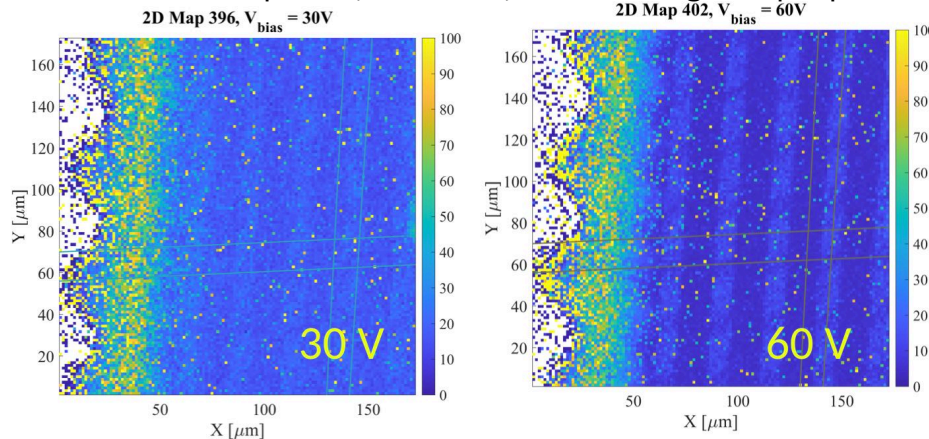
600 keV to 2 MeV Tandetron

TANDEM 1-6 MeV proton source

LASER TCT laboratory



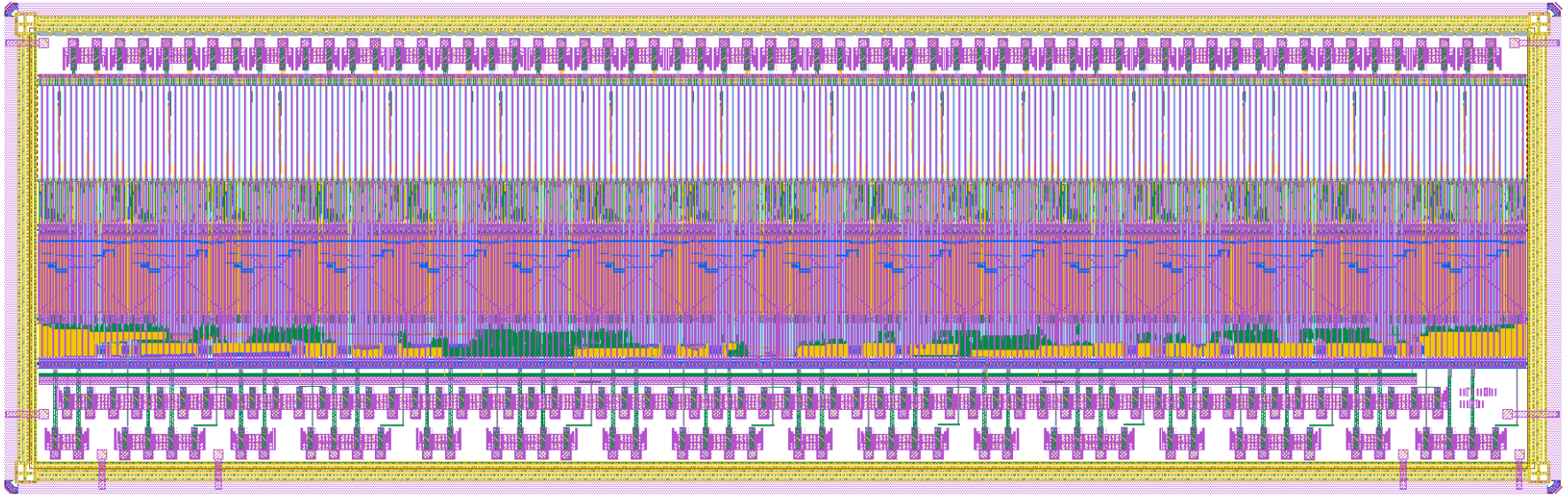
Standard deviation maps show the expected higher electronic noise when the sensor is not depleted (below 30 V), due to the higher top capacitance.



Chip Architecture



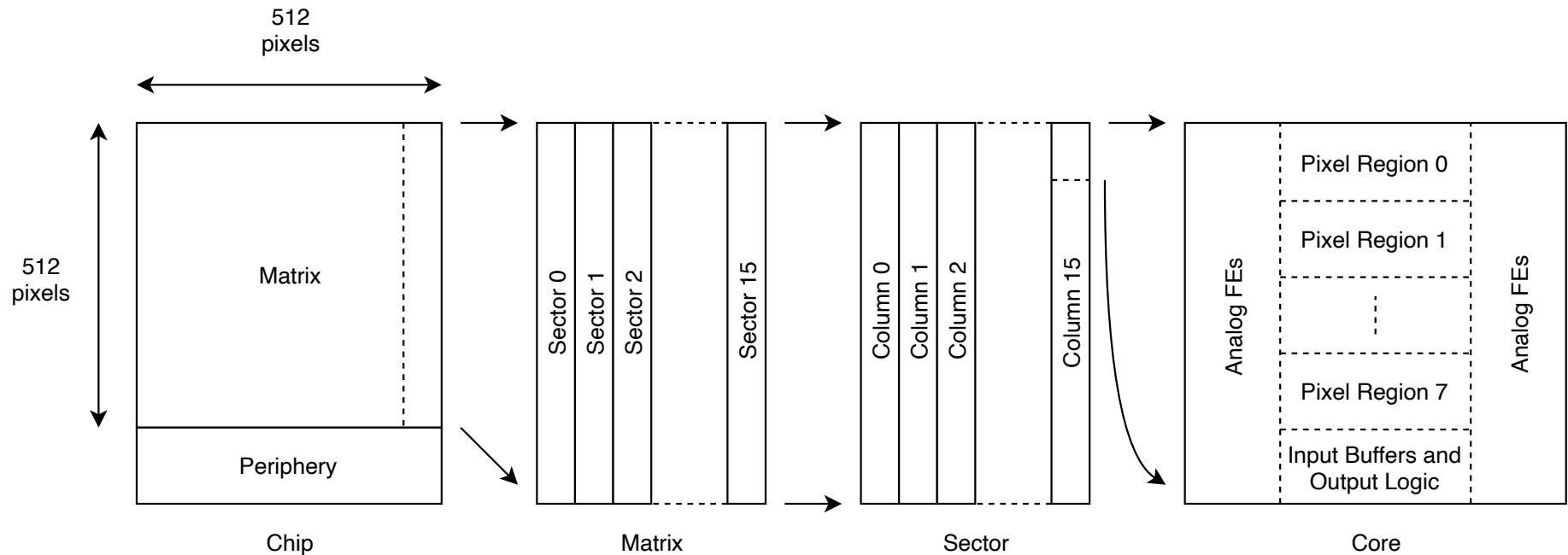
ARCADIA-MD1 - Floorplan



- * Pixel size $25\ \mu\text{m} \times 25\ \mu\text{m}$: process, back-side pattern and geometry validated in silicon
- * Matrix core 512×512 , “side-abutable” to accommodate a 512×1024 active area ($2.56 \times 1.28\ \text{cm}^2$).
- * Chip architecture and data links scalable to 2048×2048 pixels⁽¹⁾
- * Triggerless, binary readout, event rate up to $100\ \text{MHz cm}^{-2}$
- * Two flavors: full size (512×512) and mini (32×512 - pictured above)

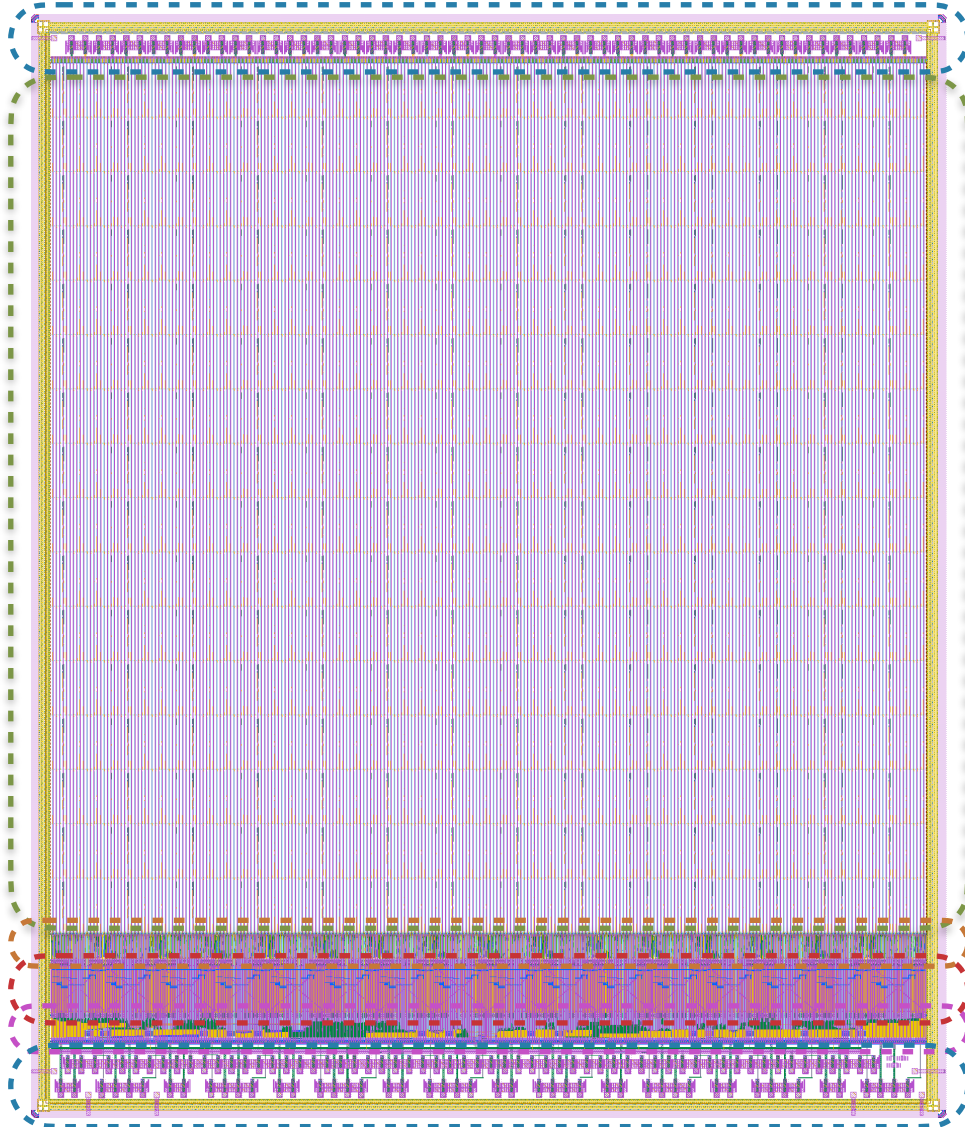
⁽¹⁾ 1D and 2D stitching available at LFoundry

ARCADIA-MD1 - Floorplan scheme



- * The Matrix is composed of 16 identical Sectors, each with independent readout and output link
- * Sectors (32x512) contain 16 Double Columns, read by a common End Of Sector logic
- * Double Columns (2x512) stack 16 Cores, the minimal synthesizable entity in the matrix
- * Cores (2x32) bundle together 8 Pixel Regions for optimal PNR and Signal Propagation

ARCADIA-MD1 - Floorplan



Top Padframe

Auxiliary supply, IR Drop Measure

Matrix

512x512 pixels, Double Column arrangement

End of Sector (x16)

Reads and Configures 512x32 pixels

Sector Biasing (x16)

Generates I/V biases for 512x32 pixels

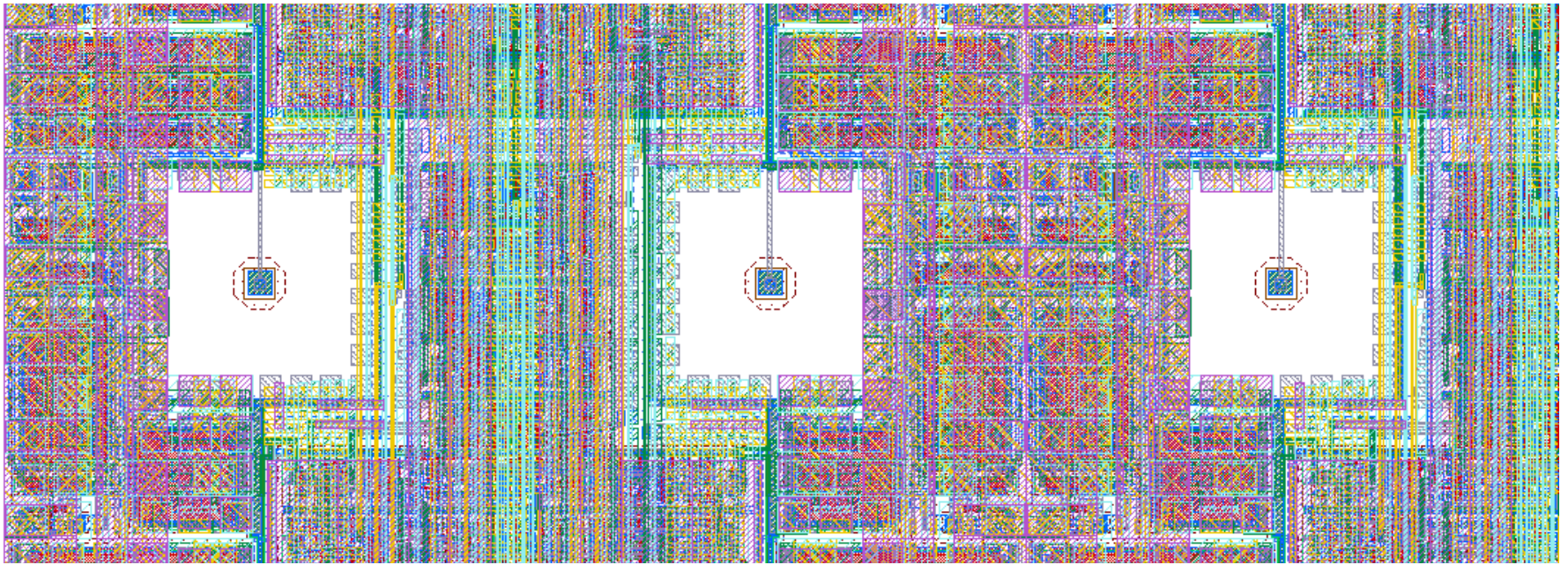
Periphery

SPI, Configuration, 8b10b enc, Serializers

Bottom Padframe

Stacked Power and Signal pads

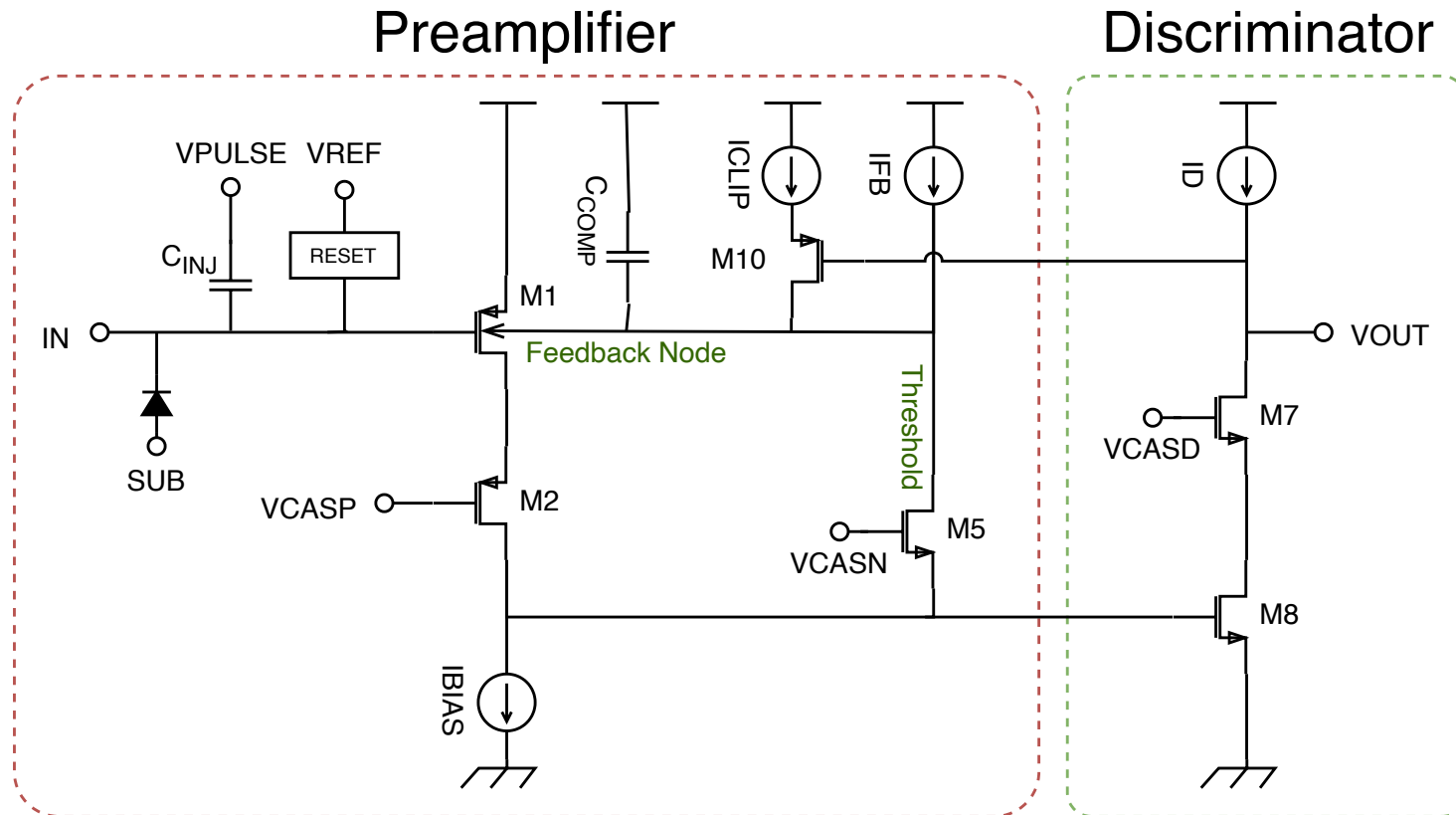
ARCADIA-MD1 - Pixels



- * The pixel's area is occupied by the collection diode (16%) and analog and digital circuits (42% both)
- * 2-bit pixel configuration for masking and injection enabling
- * Digital injection capability for readout chain testing, bypassing FEs
- * Custom power distribution scheme to maximize metal occupancy

The Analog Front-Ends





- * Small signal gain: g_{m1}/g_{m5}
- * Feedback applied to the bulk of input transistor

- * Clipping mechanism changed due to different DC voltages in this architecture

FE2 - Post-layout Simulations

Pre-amp

Center

Edge

Corner

Discr.

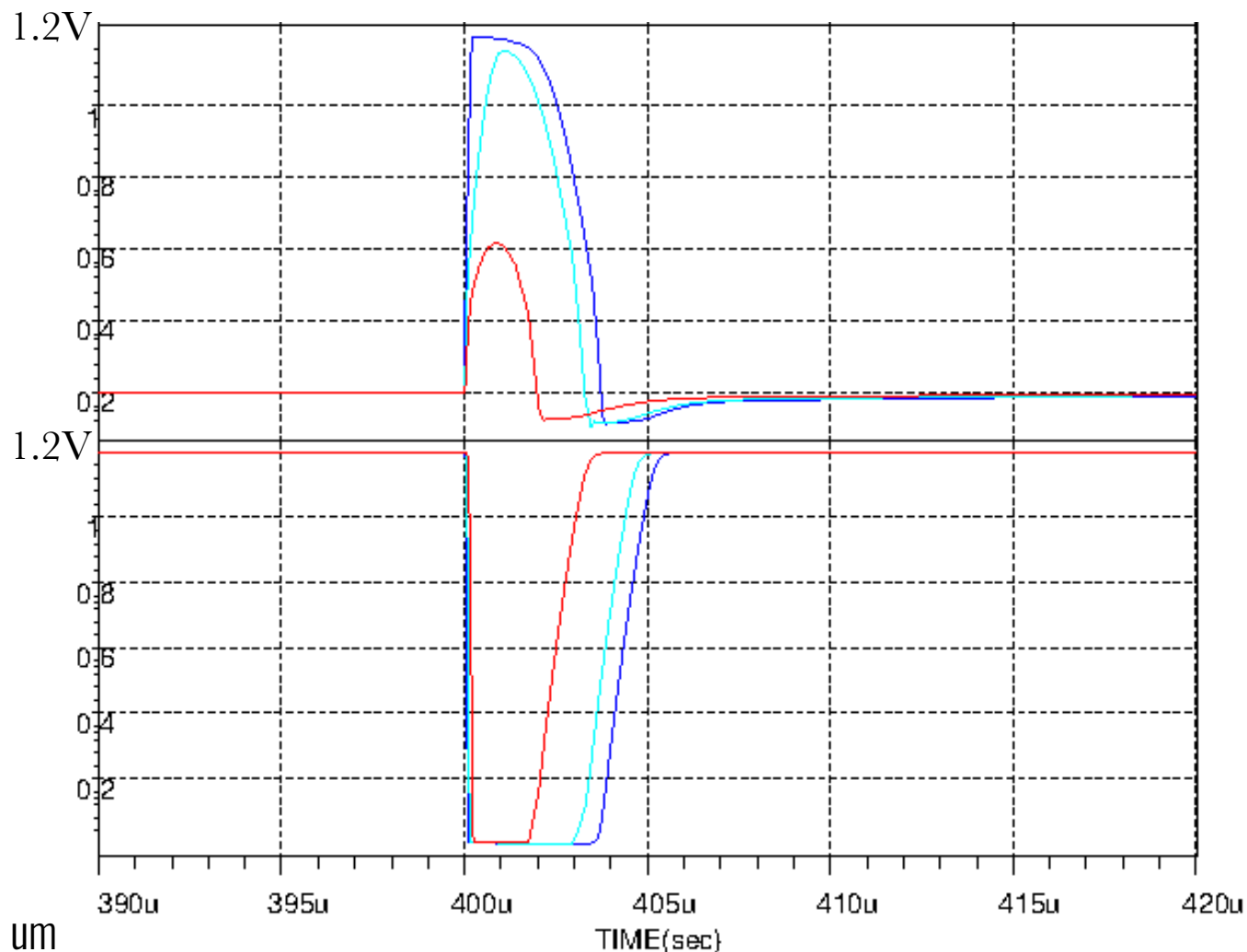
Center

Edge

Corner

* 200 MeV muons

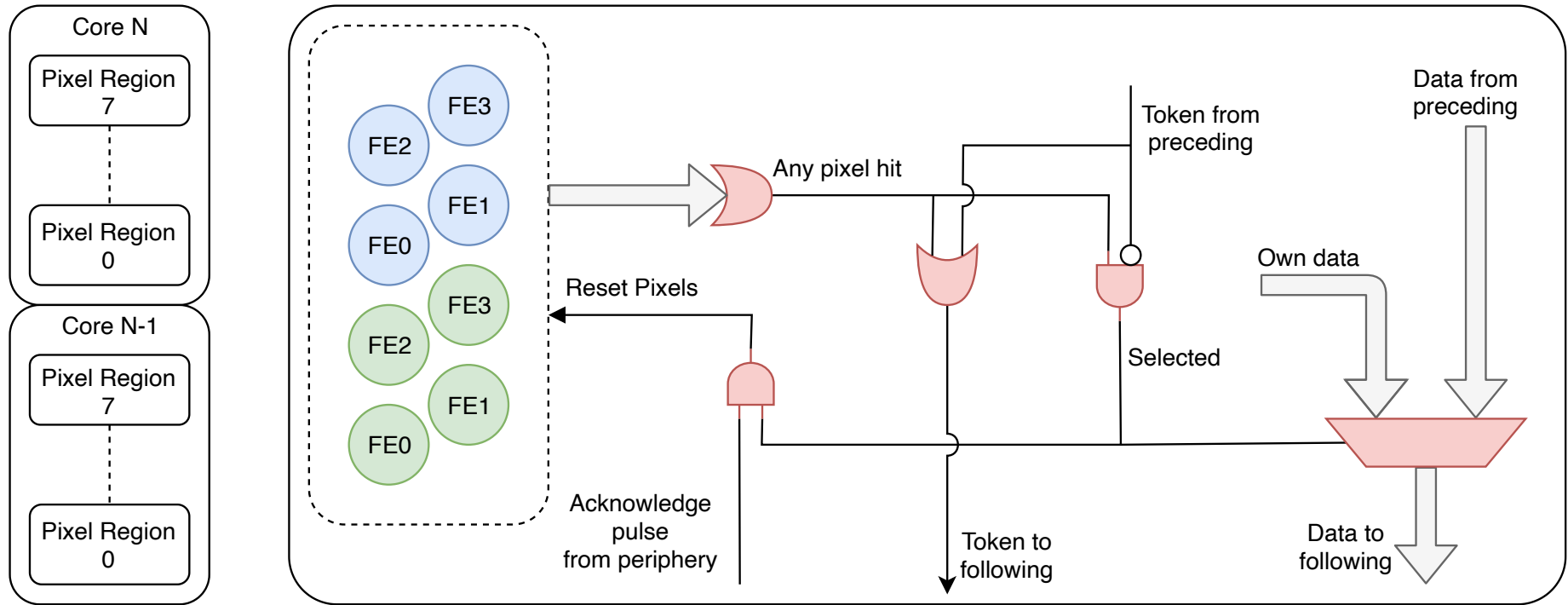
* Sensor thickness 100 μm



Readout



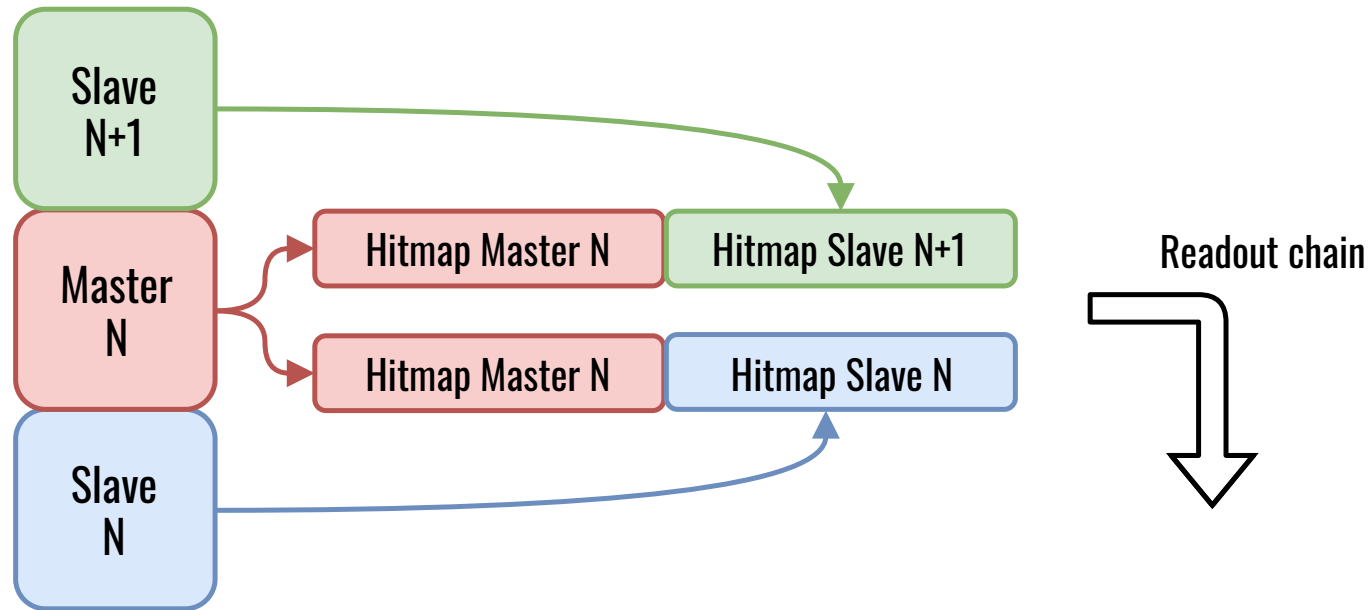
Pixel Region Schematic



* Pixel Regions use a Token chain to establish Readout Priority

* The data bus propagates: Pixel Region Hitmap and Address + Core Address

ARCADIA-MD1 - Auto-Clustering

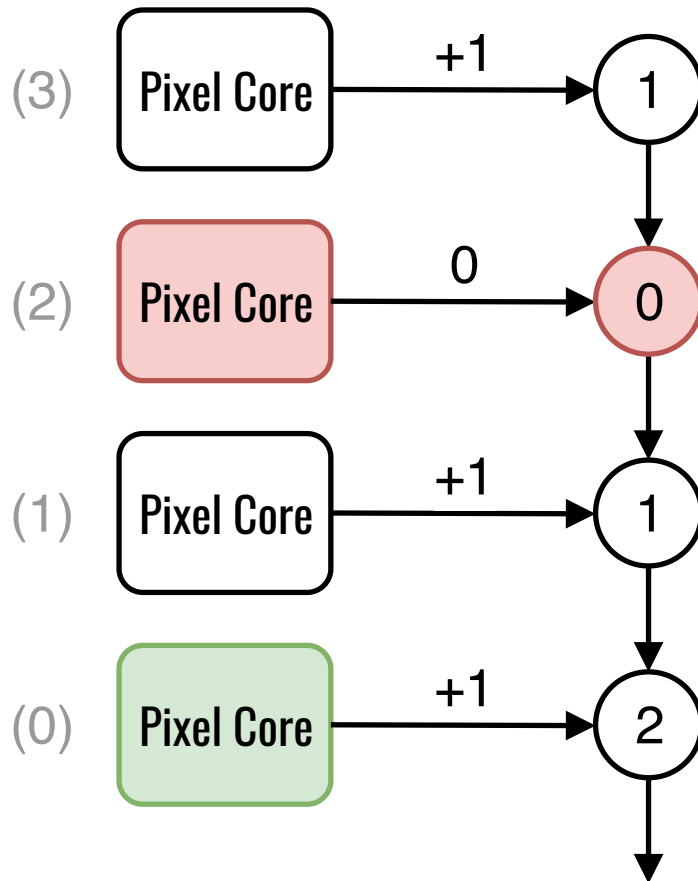


- * 4×2 pixel Regions, logically divided into a Master (2×2) and a Slave (2×2)
- * Masters propagate 4×2 pixel data packet to the periphery and await **Acknowledge** pulse
- * Master can include the hitmap of either the Top or Bottom Slave in the data packet
- * Aim: Zero suppression, reduction of bus occupancy and readout clock requirement

ARCADIA-MD1 - Indirect Addressing

Core w/ pixel hits

Core w/ priority



- * Cores are **not aware** of their own addresses or position in the matrix.
- * Core Address is **evaluated during readout** by a simple adder
- * Pixel Region Address is **hardcoded** (synthesized) in the Core logic
- * Pixel configuration must select the cores to configure **indirectly**
- * This strategy allows to **save cell area and metal interconnections**

ARCADIA-MD1 - Readout performance



	w/ Auto Clustering	w/o Auto Clustering
Event Rate	100 MHz cm ⁻²	
Matches	99,778%	99,712%
Ghost	0,004%	0,08%
Duplicate	0,11%	0,02%
Column Packet rate	15,7 MPps	19,9 MPps
Column bandwidth	443,11 Mbps	510,18 Mbps

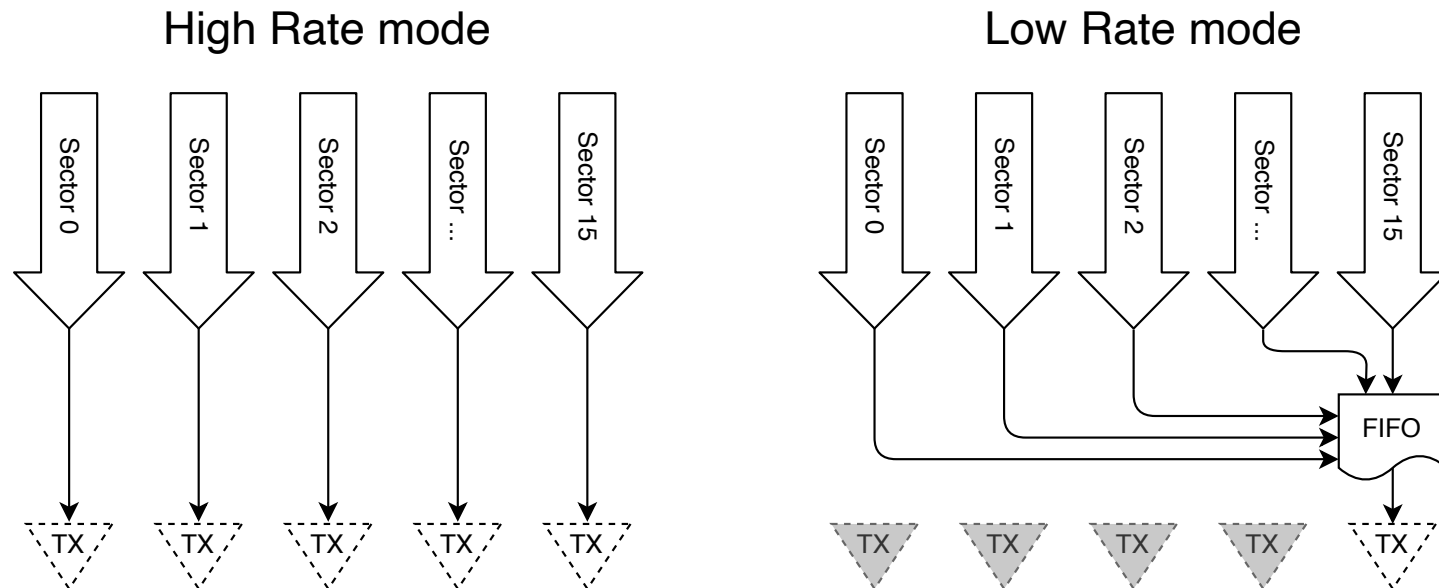
* Randomly generated clusters w/ average pixel occupancy = 4

* Auto-Clustering reduces Column BW of 67Mbps

ARCADIA-MD1 - Peripheral Dataflow



- * Each Column (32x512 pixels) has a readout BW of 443Mbps
- * Link is DC-balanced via 8b10b encoding, which increase BW requirement to 553Mbps
- * Sector data is sent out via dedicated 320MHz DDR Serializers
- * In Low Rate Mode, the first serializer processes data from all the sections. The other serializers and LVDS TXs are powered off in order to reduce power consumption.

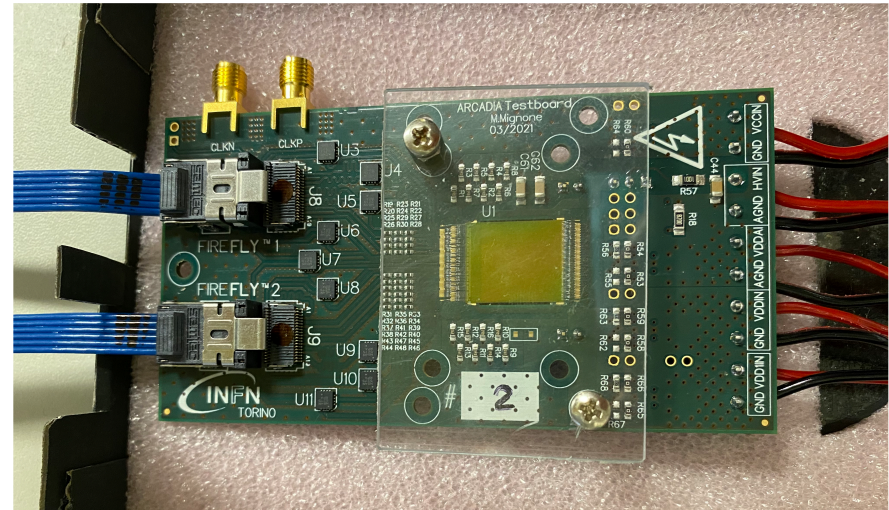
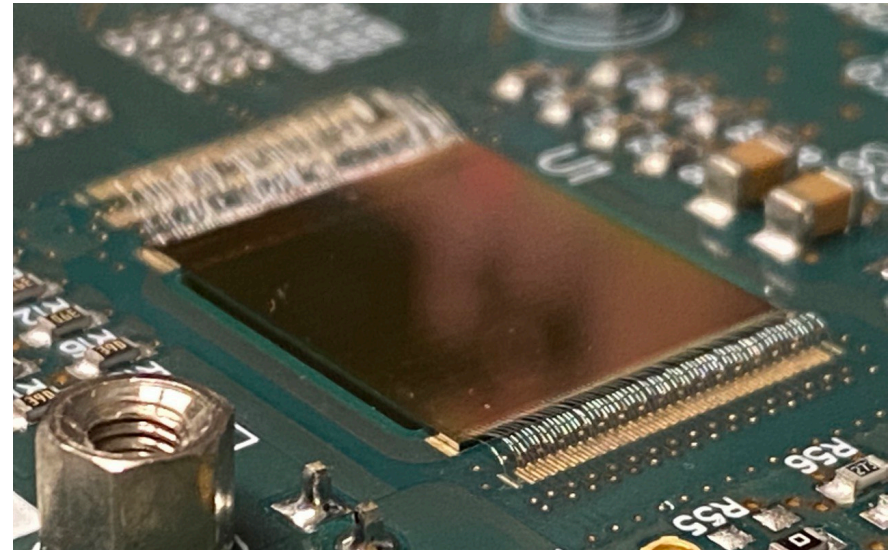


ARCADIA-MD1 Preliminary tests



Submission and Tests

- * ARCADIA-MD1 submitted in October 2020
- * Dies received in June 2021
- * Tests started soon afterwards



Conclusions



A second main demonstrator (codename ARCADIA-MD2) has been submitted in June 2021. Research has focused on power reduction, scalability.

- * 16x2 pixel Cores, 8 Cores in the Matrix
- * Logic and buffering optimization -> Acknowledge signal propagates 7 times faster!
 - * Simulations validated matrices up to 8192 pixels high
- * Optional Core addressing failsafe mechanism
- * Power optimization in the periphery
- * 1 GHz DDR serializer -> 2Gbps bandwidth!
- * Now in foundry, expected dies in October

Summary



- * The ARCADIA chips target space, medical, and future colliders applications
- * Uses a custom LFoundry 110nm CIS process
- * Chip architecture focuses on scalability to large areas, low power operation
- * Binary readout, high spatial resolution (25um pixel pitch), us timing resolution
- * Dies come in 2 flavors, with 2 different Front-Ends
- * ARCADIA-MD1 submitted in October 2020, first dies in June 2021
- * Tests on all digital and analog features confirmed the expected functionality
- * ARCADIA-MD2 submitted in May 2020, dies expected in October 2021
- * ARCADIA-MD3 to be submitted mid-2022

ARCADIA: technology platform and system-grade demonstrator architecture

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Thank You for your time !